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Mechanism of Anion-Catalyzed C-H Silylation using TMSCF₃: Kinetically-Controlled CF₃-anionoid Partitioning as a Key Parameter

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EaStChem, University of Edinburgh, Joseph Black Building, David Brewster Road, Edinburgh, EH9 3FJ, UK. *Keywords: Kinetics, Stopped-Flow NMR, Silanes, Partitioning, Carbenes, Deprotonation, Kinetic Acidity, Weak C-H acids*

ABSTRACT: The mechanism of anion-catalyzed C-H silylation by R_3SiCF_3 reagents has been investigated using homogeneous TBAT-initiation, in situ and stopped-flow ¹⁹F-NMR spectroscopy, ²H-KIE, LFER, deuterium-labelled cross-over, structure-selectivity quantitation (TMSCF₃ / TESCF₃), carbene trapping, and DFT-calculations. Analysis of the kinetics of reactions of 1,3-difluorobenzenes (2), and the generation of ArSiMe₃ and Me₃SiF as a function of the concentration of [**2**], [TMSCF₃] and [TBAT], show that a CF₃-anionoid is the active intermediate. The CF₃-anionoid is reversibly released from siliconate [(CF₃)₂SiMe₃]⁻, and undergoes partitioning through rate-limiting arene deprotonation (¹H/²H KIE 9.5) to generate ArSiMe₃ (via a transient aryl anionoid) and fluoroform (CF₃H), in competition with F-anion transfer to TMSCF₃ to generate CF₂ and TMSF. The [**2**]/[TMSCF₃] concentration ratio directly and proportionally controls the kinetics of the partition, in favor of C-H deprotonation. Higher concentrations of TBAT and lower concentrations of TMSCF₃ lead to faster rates of ArSiMe₃ generation. Use of the homologous TESCF₃ reagent leads to faster rates of anion catalysis, and an increased selectivity towards C-H deprotonation. Perfluoroalkenes, generated in situ from CF₂, capture the CF₃-anionoid leading to progressive inhibition of the anion-catalysis. Inhibition is suppressed by using a styrene additive to trap the CF₂, and the efficiency of the process enhanced by slow-addition of TMSCF₃ (1) to maintain a high concentration ratio [**2**] / [**1**].

INTRODUCTION

Over the last decade there has been surge of interest in the use of trifluoromethyltrimethylsilane (1, TMSCF₃) as a reagent for the preparation of fluorine-containing molecules.¹ The reagent is commercially-available, at scale, relatively inexpensive, has low toxicity, a long shelf-life, is easily handled (b.p. = 55 °C), and has a very wide scope of applications (Scheme 1A);¹⁻⁶ all features that have contributed to its popularity. Beginning with the pioneering work of Ruppert,⁴ and Prakash,⁵ three general classes of anion-catalyzed² reactions of TMSCF₃ have been developed: the transfer of CF₃ to electrophiles, (e.g. ketones, i),⁶ the generation and trapping of CF₂, (e.g. in alkene cycloaddition, ii);⁷ and C-H functionalization,⁸⁻¹³ typically RH \rightarrow RTMS, iii), for example in the silylation^{14,15} of suitably reactive arenes.^{10,13} All three of these processes require silaphilic initiation (X⁻), most-commonly a fluoride source.

We recently reported on the mechanisms involved in reactions (i)¹⁶ and (ii),¹⁷ Scheme 1B. Addition of a catalytic quantity of [Ph₃SiF₂][Bu₄N] (TBAT')¹⁸ to TMSCF₃ at ambient temperature results in the rapid generation of an equilibrium mixture (K_1) of [(CF₃)₂SiMe₃]⁻, TMSCF₃ (1) and a CF₃-anionoid, Scheme 1C. It is this fluxional, highly-reactive, and metastable mixture^{16,17,19} that serves as a source of both CF₃ and CF₂, depending on the reaction conditions.¹⁶⁻²⁰ For both reactions (i and ii), use of anhydrous conditions and aprotic solvents is essential to avoid competing, or exclusive, conversion of 1 to fluoroform (CF₃H).^{17,21a,c} Scheme 1. (A) Generic reactivity of TMSCF₃ (1). (B) Anioncatalyzed Reactions of 1 with carbonyls (i), ^{6,16} alkenes (ii), ^{7,17} and weak C-H acids (RH) (iii).^{10,13} (C) Equilibrium (K_1) Between [(CF₃)₂SiMe₃]⁻, TMSCF₃ (1) and [CF₃]⁻.^{16,17,19}



 $R = CCI_3$, CH_2CN , alkyne, arene, heterocycle, cyclopropene, etc.

(C)

$$\begin{array}{c}
CF_{3} & CF_{3} \\
 \downarrow & & \\
Me - Si^{-} - Me & \longleftarrow \\
Me^{-}I \\
CF_{3} & 1
\end{array}$$

$$\begin{array}{c}
CF_{3} \\
(CF_{3}]^{-} + Me^{-}Si^{-}Me \\
Me^{-}I \\
CF_{3} & 1
\end{array}$$

However, this latter mode of CF₃H production from TMSCF₃ (1) can be valuably harnessed to generate and trap transient organic anions from weakly C-H acidic species, Scheme Biii, in-cluding MeCN,^{8,9} CH₂Cl₂,⁹ CHCl₃,¹⁰ indenes,¹⁰ cyclopropenes,^{11b} activated alkyl sulphones,¹⁰ terminal alkynes,¹² and more recently arenes.^{10,13} Indeed, the scope of the latter reaction has been substantially expanded by Kondo, to allow highly regioselective C-H silvlation of nitrobenzenes, (benzo)thiophenes, benzofurans, and fluorobenzenes.¹³ Although fluoroform (CF₃H) has been qualitatively identified as a co-product in some examples of C-H silvlation by 1 (Scheme Biii),^{9,11b,13a} the roles of siliconates and the reagent (TMSCF₃, 1) have not been elucidated. Nor have the factors that govern the overall feasibility of the reaction class in general, or the apparent requirement for excess $TMSCF_3$ (1), typically 2-3 equivalents, and high loading (20-50 mol%) of anionic initiator. Herein we report on the kinetics and mechanism of C-H silvlation (Scheme Biii). To do this, we have used the reactions of 1,3-difluorobenzenes (2) described by Kondo,¹³ as a versatile platform for analysis by ¹⁹F and ²⁹Si NMR spectroscopy, LFER, KIEs, and DFT.

RESULTS AND DISCUSSION

Preliminary Studies We began by analysis of the silylation of **2a** (X=H) using TMSCF₃ (**1**, 2.1 equiv) under the heterogeneous reaction conditions reported by Kondo (1.0 M **2a**, 50 mol% CsF, 273 K, DME, 2 h).^{13a 19}F NMR spectroscopy of the product mixture indicated partial conversion of **2a** to **3a** (61%). Replacing CsF with 5 mol % TBAT¹⁸ as a soluble anionic initiator in anhydrous THF at 300 K, gave similar results (68% conversion of **2a** to **3a**). The homogeneous reaction conditions allowed monitoring of the process by in situ ¹⁹F NMR spectroscopy, as well as direct use of kinetic constants previously established for equilibrium K_1 (Scheme 1C).^{16,17} However, to avoid dangerous overpressures²¹ caused by outgassing of rapidly-evolved CF₃H (b.p. –82 °C), we used lower concentrations of **1** and **2a**, Figure 1.



Figure 1. Preliminary in situ ¹⁹F NMR spectroscopic analysis of the anion-catalyzed reaction of TMSCF₃ with **2a**. Conditions: $[1]_0 60 \text{ mM}, [2a]_0 50 \text{ mM}, \text{TBAT } 1.8 \text{ mM}, 300\text{K}, \text{THF}.$ Manual assembly and then analysis by ¹⁹F NMR spectroscopy at 300 K; for full details, see SI, section 2.3

The reactions were found to proceed relatively rapidly, resulting in absence of data for the first ~80 seconds after manual assembly of the reaction in the NMR tube. Nonetheless, the in situ ¹⁹F NMR spectroscopic analysis confirmed dynamic line broadening of TMSCF₃ (1), indicative of the expected rapid equilibrium involving [(CF₃)₂SiMe₃]⁻ (Scheme 1C) and after an initial burst of CF₃H, corresponding to consumption of trace water (22-25 ppm, KF titration), the evolution of [CF₃H] and [Ar-TMS] (3a) were directly proportional. The reactions stalled after approximately 400 seconds, at which point ~70% of 1 had been consumed, Figure 1. Further experiments employing [2D]-2a (see SI, section 3) confirmed that the dueteron of the C-D acid ([2D]-2a) emerges in CF₃D.9,11 Moreover, there was no detectable de-silvlation of the product (3a) evident from studies of the co-reaction of 2a and 4-D-3a. However, in cases where there was complete consumption of 1, there is a slow degenerate trimethylsilyl exchange between 2a and 3a (see SI, Section 3).

Reaction Kinetics, KIE and LFER Using variable-ratio stopped-flow ¹⁹F NMR spectroscopy,¹⁶ where NMR spectra can be acquired within 0.2 seconds of initiation of the reaction, a wide range of initial concentrations²² of TMSCF₃ (1), arene (2a), and TBAT, were explored, Figure 2. Together with kinetic simulations (SI section 8.6), the data show that productive turnover of 2a to 3a has a first order dependence on both the arene ([2a]_t) and the active anion concentration, (x[TBAT]₀; $1 \ge x \ge 0$), with TMSCF₃ (1) acting as an inhibitor to the process. The latter results in the reactions exhibiting a marked acceleration in the rate of generation of 3a when the evolving ratio [2a]_t/[1]_t rises above unity. The latter evident for example in Figure 2B, [2a]₀ = 51 mM, where the reaction profile switches from progressive deceleration to progressive acceleration, when [1a]₀ is reduced from 53 mM to 66 mM.

The inhibitory effect of [1] on the rate of generation of 3a, indicates that the active intermediate is a CF₃-anionoid, not the siliconate $[(CF_3)_2SiMe_3]^-$ from which it is reversibly released $(1/K_1)$. Irreversible rate-limiting deprotonation of the C-H acid by the CF₃-anionoid will generate CF₃H plus a transient anionoid, which on rapid silvlation by $TMSCF_3$ (1), releases aryl-TMS (3a) and regenerates the CF₃-anionoid. Evidence to support this conclusion comes from a large primary kinetic isotope effect at the arene C-H ($k_{\rm H}/k_{\rm D}$ = 9.5 for the reaction of **2a** versus 2-D-2a, see SI, Section 5). DFT calculations for proton transfer, after pre-complexation of the CF₃-anion and application of a tunneling correction, afforded a KIE value consistent with this process ($k_{\rm H}/k_{\rm D} = 9.7$; see SI, Section 11.3). Furthermore, a linear free energy relationship (LFER) constructed by intermolecular competition of a series of 4-substituted-1,3-difluorobenzenes gave a large positive correlation ($\rho = +5.5$) indicative of a substantial accumulation of negative charge²³ at the transition state (Figure 2D). A computationally-assessed LFER was in good agreement ($\rho_{calc} = 1.2 \rho_{exp}$; see SI, Section 11.2).

Whilst the preliminary analysis indicates some similarity to CF₃-transfer from 1,¹⁶ there are some important differences in the factors affecting selectivity and efficiency. Thus, in stark contrast to the highly efficient trifluoromethylation of ketones (Bi),⁴⁻⁶ multiple side-products are generated in the aryl silylation reaction (Biii). These do not arise from **2a** or **3a** (see material balance, Figure 1) but instead from the TMSCF₃ (1). Moreover, the reactions show clear signs of progressive inhibition of the anionic catalysis, see e.g. Figure 2C where $[TBAT]_0 \le 2.1$ mM, in some cases resulting in complete stalling ($x \rightarrow 0$) of the process prior to completion, Figure 1.



Figure 2. Kinetics, LFER and KIE for the Anion-Catalyzed Reaction of $\text{TMSCF}_3(1)$ with 2. Conditions: (A) $[1]_0$ 63 mM, TBAT 3.6 mM, 300 K, with $[2]_0$ varied from 7 to 101 mM; (B) $[2a]_0$ 51 mM, TBAT 3.6 mM, 300 K, with $[1]_0$ varied from 9 to 98 mM; (C) $[1]_0$ 65 mM, $[2a]_0$ 53 mM, 293K, with $[\text{TBAT}]_0$ varied from 0.2 to 3.5 mM (0.37 to 6.6 mol%; (D) Experimental and computed KIE and linear free energy relationship for C-H deprotonation by CF3 anionoid, see SI, sections 5, 6, 11.2, and 11.3 for full details.

Productive Fractionation and Progressive Inhibition ¹⁹F NMR spectroscopic analysis of the evolution of the side-products in the reaction system revealed two key features. Firstly, correlation of the growth of $[3a]_t$ against [TMSF]_t affords the productive fractionation of reagent 1 into C-H silylation product **3a** versus TMSF (*f*, equation 1).

$$f = \frac{v_{3a}}{v_{\text{TMSF}}}$$
 eq. 1

Analysis of the *initial* productive fractionation, f_0 , across a wide range of initial concentrations of TMSCF₃ [1]₀, arene [2a]₀, and anion [TBAT]₀, confirmed a simple dependency on the concentration ratio of the reactants, where $f_0 \approx (0.44 \ [2a]_0 / \ [1]_0)$, see Figure 3A This relationship is independent of the anion concentration, [TBAT]₀, Figure 3B. However, due to the side reactions that consume 1, the reactant ratio ([2a]_{*l*}/[1]_{*l*}) increases as the reaction evolves and the productive fractionation, *f*, rises until 2a is fully depleted (see SI section 4.4).



Figure 3. A) Initial productive fractionation, f_0 equation 1. B) Evolution of silylation product 3a versus TMSF at various [TBAT]₀. See SI section 4.4 for full details.

0.00

0.01

0.02

[TMSF1 (M)

0.03

1.5

0.5 1

[2a]₀/[1]₀

Secondly, the reactions progressively generated $[C_{11}F_{23}]^-$ (4),^{17,24} a species that we have previously identified as the product of sequential additions of the CF₃-anionoid to in situ generated perfluoroalkenes. Fluoride elimination from perfluorocarbanion 4 is strongly disfavored because both of the isomers of the corresponding perfluoroalkene are highly strained.¹⁷ As a consequence, progressive generation of $[C_{11}F_{23}]^-$ (4) results in eventual termination of the anionic catalysis in reaction (iii).

TESCF₃ versus TMSCF₃ The use of alternative reagents to 1, such as commercially-available $TESCF_3$ (7), has been reported, in a few examples, to give analogous silvlated products to reaction (iii),¹³ but with no detail on the rate or selectivity. Based on our previous studies of reactions (i) and (ii), the increased steric bulk and changes in electron density at silicon in the TES moiety are expected to have a considerable impact on the kinetics and partitioning.^{16,17} Reaction of **2a** with TESCF₃ (7) confirmed the same general features as found with reactions using TMSCF₃, i.e. co-evolution of CF₃H with the Ar-TES product (8a), and continuous TESF generation. However, compared to 1, the equilibrium of 7 with siliconate $[(CF_3)_2SiEt_3]^-$ is less favoured (calc. $K_1^{\text{TMS}} / K_1^{\text{TES}} \approx 20)^{17}$ leading to higher equilibrium concentrations of the CF₃-anionoid.¹⁶ Stopped-flow ¹⁹F NMR spectroscopy of the reaction confirmed considerably faster anion-catalyzed reaction of 2a with TESCF₃(7), as compared to $TMSCF_3$ (1). Indeed, reactions conduced solely with TESCF₃ (7) required reduced catalyst loading (1.8 mol%) TBAT) and higher substrate concentrations to allow ¹⁹F NMR spectroscopic monitoring of the reaction evolution, which still proceeded to 95% conversion in about 7 seconds, Figure 4A. Moreover, when normalized by reactant ratio $([2a]_0/[1,7]_0)$, reactions with $TESCF_3(7)$ proceed with about twenty-fold greater initial productive fractionation, f_0 , than 1, consistent with the lower propensity for TESF + $(CF_2)_n$ generation from 7.¹⁷

To further compare the reactivity of the two silanes we coreacted them with arene **2a** under various conditions, see Figure 4B (and SI Section 7 for further examples), revealing some remarkable features. Consistent with 7 being the more hindered silylating reagent, transfer of the TMS group to generate **3a**, occurs preferentially to transfer of TES, to generate **8a**. However, the process by which this occurs is not simply a direct competition between reagents **1** and **7**. For example, after initiation of anionic catalysis, an equimolar mixture of **1** and **7** generate the

corresponding fluorosilanes, TMSF and TESF, at a similar initial rate: $v_0 TMSF/v_0 TESF \sim 1$, but the silvlation product is almost exclusively Ar-TMS (3a). We have previously shown that the isodesmic equilibrium shown in Scheme 2 (K_{Si} , $\Delta G_{300} \le 0.2$ kcal/mol, DFT) is catalyzed by the CF₃-anionoid,¹⁷ and during reaction of 2a with 1 + 7, there is dynamic line-broadening of both the TESF and TMSF signals in the ¹⁹F NMR spectrum, see SI Section 7.2B. A large proportion of the TMSCF₃ (1) also undergoes competing decomposition to TMSF. However, the TMSF is recycled to TMSCF₃ by the TESCF₃ with co-generation of TESF, Scheme 2. Consequently, for first part of the reaction (Fig 4B), the nascent aryl anion from 2a, predominantly reacts with TMSCF₃ (1) leading to generation of **3a**. As the system evolves, the available sources of TMS (1 + TMSF) are progressively depleted and the nascent aryl anion from 2a is increasingly captured by $TESCF_3$ (7) to generate 8a, with very little competing generation of TESF. Notably, the TMSCF₃ is a more powerful inhibitor than $TESCF_3$ (7), and the rate is supressed compared to using solely $TESCF_3$ (7); compare Figures 4A and 4B.



Figure 4. (A) Reactivity of TESCF₃ as silylating agent; (B) Coreaction of TESCF₃ with TMSCF₃. Conditions: (A), [7]₀ 220 mM, [**2a**]₀ 200 mM, TBAT 1.8 mo% (3.6 mM), 300K, THF. (B) [**1**]₀ = [7]₀ 105 mM, [**2a**]₀ 175 mM, TBAT 3.1 mol% (5.4 mM) 300K. The much faster reactions with solely 7 (Figure A) required lower catalyst loadings and higher substrate concentrations for effective analysis by variable-ratio stopped-flow ¹⁹F NMR spectroscopy at 300 K, for full details, see SI, section 7.





Overarching Mechanism for Anion-catalyzed Silylation of Weak C-H acids by TMSCF₃ The investigation outlined

above allows the construction of a general mechanism for the C-H silvlation process, Scheme 3. The key steps are: i) rapid release of a CF₃-anionoid $(k_{-1}, 4 \times 10^3 \text{ s}^{-1}, \text{ at } 300 \text{ K})^{17}$ from the dominant anion, siliconate [(CF₃)₂SiMe₃]⁻; ii) reaction of the CF₃-anionoid with the C-H acid (RH, k_2) to generate CF₃H. iii) silvation of the resultant transient carbanion ($[R]^-$, k_4) by TMSCF₃; iv) complexation of the CF₃-anionoid with TMSCF₃ (k_1) to regenerate [(CF₃)₂SiMe₃]; v) fluoride-transfer (k_3) from the CF₃-anionoid to TMSCF₃ to generate CF₂ and fluorosiliconate $[(CF_3)Si(F)Me_3]^{-}$;¹⁹ vi) TMSF dissociation (k_{-5}); and vii) anion-mediated homologation (k_6) generating perfluoroalkenes (C_nF_{2n}) . The two competing processes $(k_2 \text{ and } k_3)$ kineticallycontrol and thus govern the feasibility of the process: the greater the kinetic C-H acidity of the substrate (RH, k_2), the greater the intrinsic efficiency. For arene 2a, the CF₃-anionoid partitioning (Figure 3) makes the process feasible but rather inefficient, with a significant proportion of the TMSCF₃ (1) being consumed non-productively via k₃, and subsequent CF₃-anionoid catalyzed homologation (*n*) by **1**, co-generating further TMSF.

Scheme 3. General Mechanism for Anion-Catalyzed Silylation of weak C-H acids (R-H) by TMSCF₃ (1).



Practical implications of the CF₃-anion partition (k_2/k_3) For the general mechanism shown in Scheme 3, the rate of consumption of TMSCF₃ (1) is described by equation 2, where *x* is the mol-fraction of anion in non-terminated form $(1 \ge x \ge 0)$ and *n* is the average degree of anion-induced homologation (k_6) . The productive fractionation, *f*, of TMSCF₃ (1) into the silylation product (RTMS) is given by equation 3, and the rate of generation of the silylation product by equation 4. Although the partitioning constants (k_2, k_3) are fixed $(k_2$ by the kinetic acidity of the C-H acid, and k_3 by the reagent 1), equations 2-4 guide the design of reaction conditions to maximize the rate and efficiency of the process.

$$\frac{-d[\mathbf{1}]}{dt} \approx \frac{x[\text{TBAT}]_0 \left(k_2[\text{RH}]_t + n.k_3[\mathbf{1}]_t\right)}{1 + K_1[\mathbf{1}]_t + K_5[\text{TMSF}]_t} \quad \text{eq. 2}$$

$$f_t = \frac{v_{\text{RTMS}}}{v_{\text{TMSF}}} \approx \frac{k_2 [\text{RH}]_t}{n.k_3 [\mathbf{1}]_t} \quad \text{eq. 3}$$

$$\frac{d[\text{RTMS}]}{dt} \approx \frac{x[\text{TBAT}]_0 k_2[\text{RH}]_t}{1 + K_1[1]_t + K_5[\text{TMSF}]_t} \quad \text{eq. 4}$$

For example, the greater the extent of anion-induced homologation, (k_6 ; $n \ge 1$) the more extensive the progressive inhibition (k_{1nh}) of catalysis. Thus, for a given initial concentration of C-H acid (RH) and **1**, there will be a minimum initial anion concentration ([TBAT]₀) required to reach full conversion of **1**; below this value reactions stall due to complete anion sequestration in species such as $[C_{11}F_{23}]^-$ (**4**). For example, stopped-flow ¹⁹F NMR spectroscopic analysis of the reaction of [**2a**]₀ = 150 mM, with [**1**]₀ = 180 mM, initiated by 5.3 mol% TBAT, shows progressive inhibition approximately 30 seconds after initiation, and the reaction eventually stalls ($x \rightarrow 0$) reaching ~30% conversion of **2a** to **3a**, Figure 5.



Figure 5. Use of an alkene additive (5) to trap CF₂, and sustain anionic catalysis of the C-H silylation process ($2a \rightarrow 3a$). Analysis by variable-ratio stopped-flow ¹⁹F NMR spectroscopy at 300 K, for full details, see SI section 8.4. Dashed line is the calculated limiting rate and efficiency (equations 3 and 4, n = 1) see SI section 8.6.

Scheme 4. Maximizing productive fractionation, *f*, equation 3, by maintaining a high concentration ratio of [2a]/[1].^{*a*}

A) Reaction without alkene additive TMS TMSCF₃ (1) NMR Yield 1 (1.26 equiv) 3a (%) Addition TBAT (5 mol %) 61 fast THF, 25 °C 94 slow За 2a 1 mmol B) Reaction with alkene additive 1 (1.26 equiv) TMS TMSCF₃ (1) NMR Yield TBAT (5 mol %) 3a (%) Addition THF, 25 °C 70 fast 98 slow 2a 4-F-C₆H₄ 3a 1 mmol 5 (85 mol%)

^{*a*} Conditions: **1** added as a 2.1 M solution in under 2 sec ('fast') or over 72 mins ('slow') to a solution of **2a** (2.5 M) + TBAT. [**2a**+**3a**]_{final} = 1.0 M; [Si]_{final} = 1.26 M. For full details, see SI, section 8.2.

One way to attenuate the anion-induced homologation (k_x) is by diverting the nascent difluorocarbene.^{7,17} This has the effect of increasing the productive fractionation, in the limit to n = 1(equation 3), and in doing so attenuating the progressive inhibition via perfluoroalkene generation. By using styrene 5 (18 mol%; Figure 5) as an efficient CF₂ trap, the reaction proceeds to completion (100 % conversion of 1) and with $\sim 60\%$ conversion of 2a to 3a. Increased co-loadings of styrene 5 lead to faster overall rates of generation of 3a, up to a limiting value beyond which the active anion is maintained throughout ($x \approx 1$). Kinetic simulations (see SI section 8.6) suggest that $k_2/k_3 = 1.1$, and thus in the absence of alkene additive (Figure 3) $n \approx 2.5$ in the initial stages of reaction. The simulations also require weak inhibition by TMSF,²⁵ a feature consistent with the pronounced line-broadening of the TMSF ¹⁹F NMR signal that is observed as the siliconate speciation repopulates from $[(CF_3)_2SiMe_3]^{-1}$ (K_1) to $[(CF_3)Si(F)Me_3]^-(K_5, where K_1/K_5 \approx 8)^{19}$ during the final stages of consumption of 1 (see SI section 8.4).

Furthermore, equation 3 indicates that both the rate and selectivity of conversion of 1 to the C-H silylation product are proportional to the concentration ratio $[RH]_t / [1]_t$. However, reducing the total concentration of 1, limits the overall achievable conversion of the substrate (RH). This limiting effect can be bypassed through slow-addition of 1 to the reaction. This maximizes [RH] / [1] and thus the productive fractionation, f, throughout the process, Scheme 4.

CONCLUSIONS

Using variable-ratio stopped-flow ¹⁹F and ²⁹Si NMR spectroscopy, isotopic labelling, and DFT-calculations, the dual role of TMSCF₃ as a silylating reagent and source of base in the general process $1 + RH \rightarrow RTMS + CF_3H$, has been elucidated, Scheme 3. by using a series of 1,3-difluorobenzene substrates (2). As with reactions (i) and (ii), Scheme 1B, the vast majority of the active anion is present in siliconate reservoirs, primarily [(CF₃)₂SiMe₃]^{-16,17,19}

The kinetics (equations 3, 5), KIE ($k_{\rm H}/k_{\rm D} = 9.5$) and LFER ($\rho = + 5.5$), indicate that irreversible deprotonation of RH (k_2) by the rapidly and reversibly liberated CF₃-anionoid is the ratelimiting step in the productive process yielding the C-H silylation product. Competing fluoride transfer¹⁷ (k_3) from the CF₃anionoid to TMSCF₃ (1) leads to a partition (k_2/k_3) that dictates the impact of the concentrations ([1] and [RH]) on the productive fractionation, *f*, equation 4. The fluoride transfer (k_3) generates TMSF and CF₂, which undergoes anion-catalyzed homologation (*n*) with 1 to generate further TMSF and perfluoroalkenes. This is detrimental not just to the efficiency of the C-H silylation with respect to 1, but also causes inhibition, and eventual termination of catalysis (equations 3 and 5, $x \rightarrow 0$) by anion sequestration in [C₁₁F₂₃]⁻ (4)^{17,24} and analogous species.

Addition of an alkene (styrene 5, Figure 5) to trap nascent CF_2 , and slow addition of 1, raise the productive fractionation, f (equation 4), attenuate homologation (n) and retard inhibition, Scheme 4. The TBAT initiates anionic catalysis, but other than controlling the rate (equations 3 and 5) its initial concentration does not affect the selectivity. Replacing TMSCF₃ (1) by the commercially-available, but more expensive reagent TESCF₃ (7) provides higher efficiency as a result of its lower reactivity (both K_1 and k_3) towards the CF₃-anionoid. By using a mixture of 1 and 7, anion catalyzed CF₃ / F exchange (Scheme 2) allows

the bulkier reagent 7 to act as a surrogate source of CF_3 for TMS transfer, Figure 4B.

Overall, the CF₃-anionoid partitioning, f, is identified as the key parameter for both the lifetime of the active catalyst system, and the efficiency by which the silylating reagent is converted into the desired product. This conclusion leads to the general guidelines shown below for reactions involving anion-catalyzed silylation of a weak C-H acid (RH) by **1**.

- The anion pre-catalyst concentration does not influence the productive fractionation, but does affect the rate. When extensive anion-inhibition is evident (via ¹⁹F NMR detection of [C₁₁F₂₃]⁻, 4) higher homogeneous catalyst loadings (e.g. TBAT in THF) can be employed. Kondo's conditions, ¹³ employing a heterogenous initiator (CsF in DME at 0°) are highly effective, and the initiator can be used in excess.
- Addition of a sacrificial alkene to consume CF₂, strongly suppresses inhibition of the anion catalyst. High concentrations of alkene afford better selectivity, and thus use of a volatile electron-rich alkene (e.g. cyclohexene) in large excess will allow easy separation from the final reaction mixture, together with the difluorocyclopropanation product.
- Use of the minimum stoichiometry of silylating agent (1) required to effect full conversion of R-H to R-Si increases the rate and the efficiency. Slow, or aliquot-based addition of the silylating agent maintains a high ratio of [R-H]/[1], leading to greater productive fractionation.
- Use of a sterically bulky silvating agent, e.g. TESCF₃ (7) increases the dynamic concentration of the CF₃ anionoid, and reduces the extent of CF₂-generation, leading to higher rates and higher productive fractionation.

The results presented above may also aid in the design of reagents and conditions to expand the scope for generation and interception of transient carbanions by C-H deprotonation (k_2). Moreover, the readily-determined partitioning factor ($k_2/n.k_3$, Figure 3; $n \approx 2.5$ in THF at 300 K) may be useful in a more general sense to assess the relative kinetic acidity of other C-H species,²⁶ by monitoring the relative rates of evolution of CF₃H versus TMSF by ¹⁹F NMR spectroscopy.²⁷

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Notes

The authors declare no competing financial interest.

ASSOCIATED CONTENT

Experimental details, reaction profiles and characterization data can be found in the Supporting Information. This material is available free of charge via the Internet at http://pubs.acs.org.

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(22) Because of the open-venting of the system at the terminus of the flow arrangement, the specific design of stopped-flow NMR system employed (see SI) is less hazardous (in terms of limiting reagent concentrations / CF_3H gas-evolution and over-pressures) than conducting the reactions in sealed NMR tubes. This allowed slightly higher concentrations of **1**, **7** and **2** to be employed.

(23) The correlation with σ , rather than σ^- , is consistent with the development of an anion orthogonal to the π -system of the aromatic ring, and the meta-orientation of the modifying substituent to the site of deprotonation (X, Figure 2D)

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(27) This requires that the C-H acid be irreversibly deprotonated and then rapidly silylated, i.e. $k_4[1][R^-] >> k_2[CF_3][RH]$. Competition of a C-H acid with, e.g. **2a**, can be used to determine if this condition is valid.



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